RAM Fee History Query
Revenue Accounting and Management

Name/Number: 09669159

Total Records Found: 4

Start Date: Any Date

End Date: Any Date

Accounting Date	Sequence Num.	Tran Type	Fee Code	Fee Amount	Mailroom Date	Payment Method
10/05/2000	00000128	1	101	$690.00	09/25/2000	DA 190033
10/31/2000	00000038	1	581	$40.00	09/25/2000	DA 190033
07/05/2001	00000058	1	142	$1,240.00	06/29/2001	DA 190033
07/05/2001	00000059	1	561	$12.00	06/29/2001	DA 190033

L Number	Hits	Search Text	DB	Time stamp
1	2356544	strip$ or ash$ or remov$	USPAT; US-PGPUB	2004/06/24 14:59
2	66045	resist? or photoresist? or photopolymer?	USPAT; US-PGPUB	2004/06/24 14:58
3	1063	hard with mask?	USPAT; US-PGPUB	2004/06/24 14:58
4	8781	buffer with layer?	USPAT; US-PGPUB	2004/06/24 14:58
5	2195737	etch$ or patern$ or remov$	USPAT; US-PGPUB	2004/06/24 14:58
6	5266	(strip$ or ash$ or remov$) with (resist? or photoresist? or photopolymer?)	USPAT; US-PGPUB	2004/06/24 14:42
7	13	((strip$ or ash$ or remov$) with (resist? or photoresist? or photopolymer?)) same ((hard with mask?) or (buffer with layer?))	USPAT; US-PGPUB	2004/06/24 14:42
8	13	(((strip$ or ash$ or remov$) with (resist? or photoresist? or photopolymer?)) same ((hard with mask?) or (buffer with layer?))) same (etch$ or patern$ or remov$)	USPAT; US-PGPUB	2004/06/24 14:45
9	27336	antireflect$ or (anti with reflect$)	USPAT; US-PGPUB	2004/06/24 14:58
10	38	((strip$ or ash$ or remov$) with (resist? or photoresist? or photopolymer?)) same (antireflect$ or (anti with reflect$)) same (etch$ or patern$ or remov$)	USPAT; US-PGPUB	2004/06/24 14:45
11	35	(((strip$ or ash$ or remov$) with (resist? or photoresist? or photopolymer?)) same (antireflect$ or (anti with reflect$)) same (etch$ or patern$ or remov$)) not (((strip$ or ash$ or remov$) with (resist? or photoresist? or photopolymer?)) same ((hard with mask?) or (buffer with layer?)))	USPAT; US-PGPUB	2004/06/24 14:51
12	38	(resist? or photoresist? or photopolymer?) same (hard with mask?) same (etch$ or patern$ or remov$)	USPAT; US-PGPUB	2004/06/24 14:52
13	25	((resist? or photoresist? or photopolymer?) same (hard with mask?) same (etch$ or patern$ or remov$)) not ((((strip$ or ash$ or remov$) with (resist? or photoresist? or photopolymer?)) same ((hard with mask?) or (buffer with layer?))) or (((strip$ or ash$ or remov$) with (resist? or photoresist? or photopolymer?)) same (antireflect$ or (anti with reflect$)) same (etch$ or patern$ or remov$)))	USPAT; US-PGPUB	2004/06/24 14:52
14	21250	resist? or photoresist? or photopolymer?	JPO; DERWENT	2004/06/24 14:58
15	1599663	etch$ or patern$ or remov$	JPO; DERWENT	2004/06/24 14:58
16	12942	antireflect$ or (anti with reflect$)	JPO; DERWENT	2004/06/24 14:58
17	176	hard with mask?	JPO; DERWENT	2004/06/24 14:58
18	3179	buffer with layer?	JPO; DERWENT	2004/06/24 14:59
19	60	(resist? or photoresist? or photopolymer?) and (etch$ or patern$ or remov$) and ((antireflect$ or (anti with reflect$)) or (hard with mask?) or (buffer with layer?))	JPO; DERWENT	2004/06/24 14:59
20	1858051	strip$ or ash$ or remov$	JPO; DERWENT	2004/06/24 14:59
21	1540	(resist? or photoresist? or photopolymer?) with (strip$ or ash$ or remov$)	JPO; DERWENT	2004/06/24 14:59
22	21	((resist? or photoresist? or photopolymer?) and (etch$ or patern$ or remov$) and ((antireflect$ or (anti with reflect$)) or (hard with mask?) or (buffer with layer?))) and ((resist? or photoresist? or photopolymer?) with (strip$ or ash$ or remov$))	JPO; DERWENT	2004/06/24 15:00

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| 23 | 39 | ((resist? or photoresist? or photopolymer?) and (etch$ or patern$ or remov$) and ((antireflect$ or (anti with reflect$)) or (hard with mask?) or (buffer with layer?))) not (((resist? or photoresist? or photopolymer?) and (etch$ or patern$ or remov$) and ((antireflect$ or (anti with reflect$)) or (hard with mask?) or (buffer with layer?))) and ((resist? or photoresist? or photopolymer?) with (strip$ or ash$ or remov$))) | JPO; DERWENT | 2004/06/24 15:00 |